2SJ556

Silicon P Channel MOS FET High Speed Power Switching

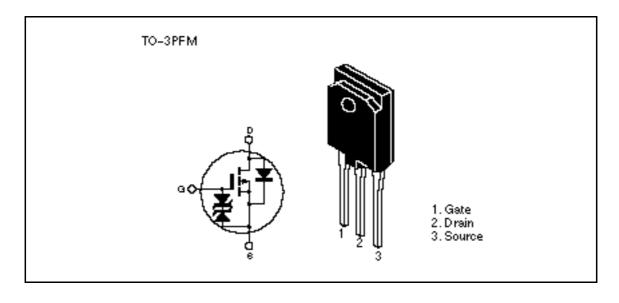
HITACHI

ADE-208-645A (Z) 2nd. Edition Jun 1998

Features

- Low on-resistance $R_{DS(on)} = 0.028 \quad typ. \label{eq:RDS(on)}$
- Low drive current.
- 4V gate drive devices.
- High speed switching.

Outline





2SJ556

Absolute Maximum Ratings ($Ta = 25^{\circ}C$)

Item	Symbol	Ratings	Unit
Drain to source voltage	$V_{\scriptscriptstyle DSS}$	– 60	V
Gate to source voltage	V_{GSS}	±20	V
Drain current	I _D	–45	A
Drain peak current	Note1 D(pulse)	-180	A
Body-drain diode reverse drain current	I _{DR}	-45	A
Avalanche current	I _{AP} Note3	–45	A
Avalanche energy	E _{AR} Note3	173	mJ
Channel dissipation	Pch Note2	60	W
Channel temperature	Tch	150	°C
Storage temperature	Tstg	-55 to +150	°C

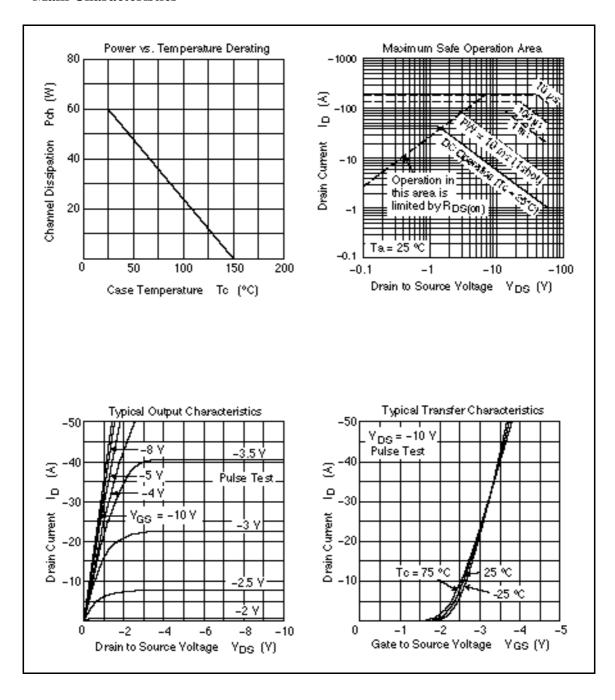
- Note: 1. PW 10 µs, duty cycle 1 %
 - 2. Value at $Tc = 25^{\circ}C$
 - 3. Value at Tch = 25°C, Rg 50

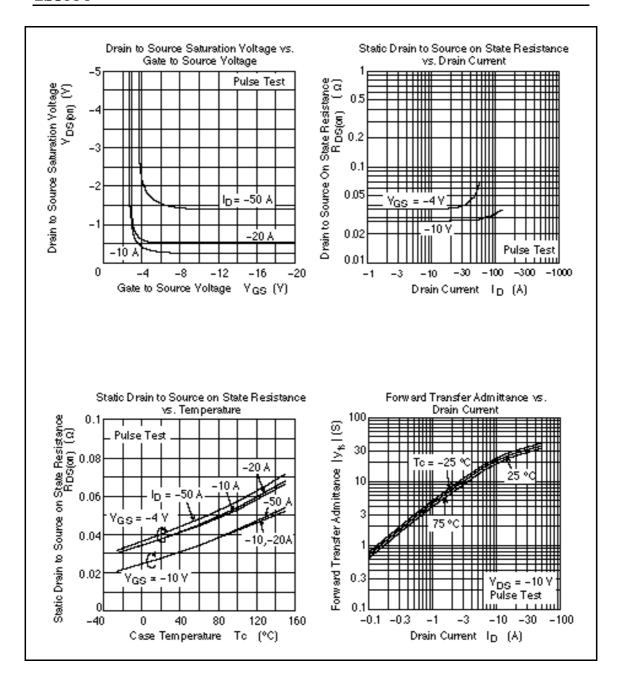
Electrical Characteristics ($Ta = 25^{\circ}C$)

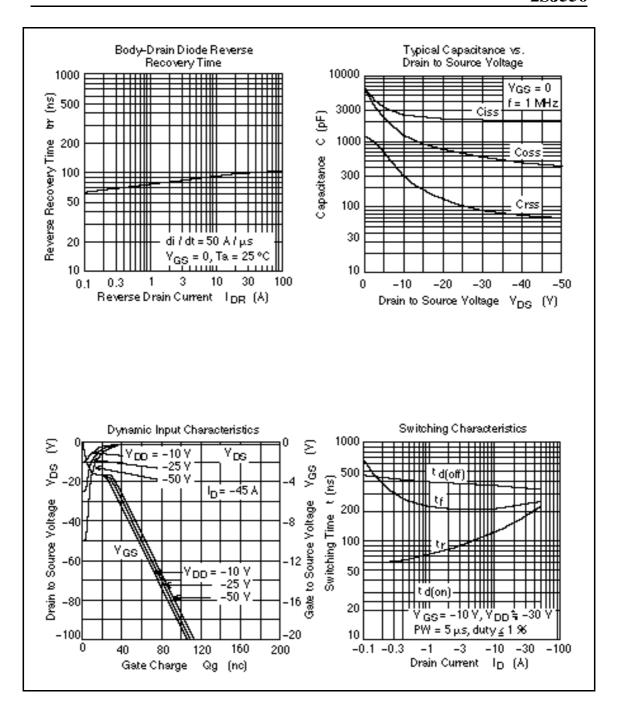
Item	Symbol	Min	Тур	Max	Unit	Test Conditions
Drain to source breakdown voltage	$V_{(BR)DSS}$	-60	_	_	V	$I_D = -10 \text{mA}, V_{GS} = 0$
Gate to source breakdown voltage	$V_{(BR)GSS}$	±20	_	_	V	$I_G = \pm 100 \mu A, V_{DS} = 0$
Zero gate voltege drain current	I _{DSS}	_	_	-10	μΑ	$V_{DS} = -60 \text{ V}, V_{GS} = 0$
Gate to source leak current	I _{GSS}	_	_	±10	μΑ	$V_{GS} = \pm 16V, V_{DS} = 0$
Gate to source cutoff voltage	$V_{GS(off)}$	-1.0	_	-2.0	V	$I_{D} = -1 \text{mA}, V_{DS} = -10 \text{V}$
Static drain to source on state	$R_{\mathrm{DS(on)}}$	_	0.028	0.037		$I_D = -25A, V_{GS} = -10V^{Note4}$
resistance	R _{DS(on)}	_	0.038	0.055		$I_{D} = -25A, V_{GS} = -4V^{Note4}$
Forward transfer admittance	y _{fs}	18	30	_	S	$I_D = -25A, V_{DS} = -10V^{Note4}$
Input capacitance	Ciss	_	2500	_	pF	$V_{DS} = -10V$
Output capacitance	Coss	_	1300	_	pF	$V_{GS} = 0$
Reverse transfer capacitance	Crss	_	300	_	pF	f = 1MHz
Turn-on delay time	t _{d(on)}	_	25	_	ns	$V_{GS} = -10V, I_{D} = -25A$
Rise time	t _r	_	160	_	ns	R _L = 1.2
Turn-off delay time	$t_{d(off)}$	_	350	_	ns	-
Fall time	t _f	_	240	_	ns	-
Body-drain diode forward voltage	V_{DF}		-1.1	_	V	$I_F = -45A, V_{GS} = 0$
Body–drain diode reverse recovery time	t _{rr}	_	100	_	ns	$I_F = -45A, V_{GS} = 0$ diF/ dt =50A/ μ s

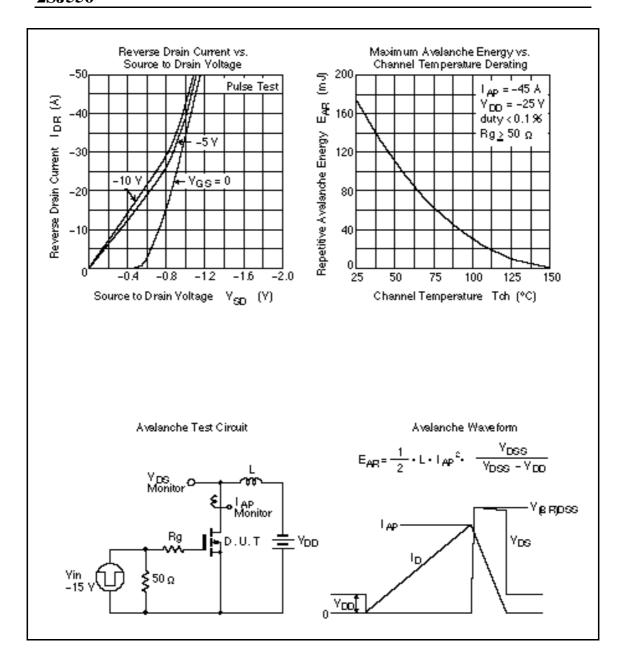
Note: 4. Pulse test

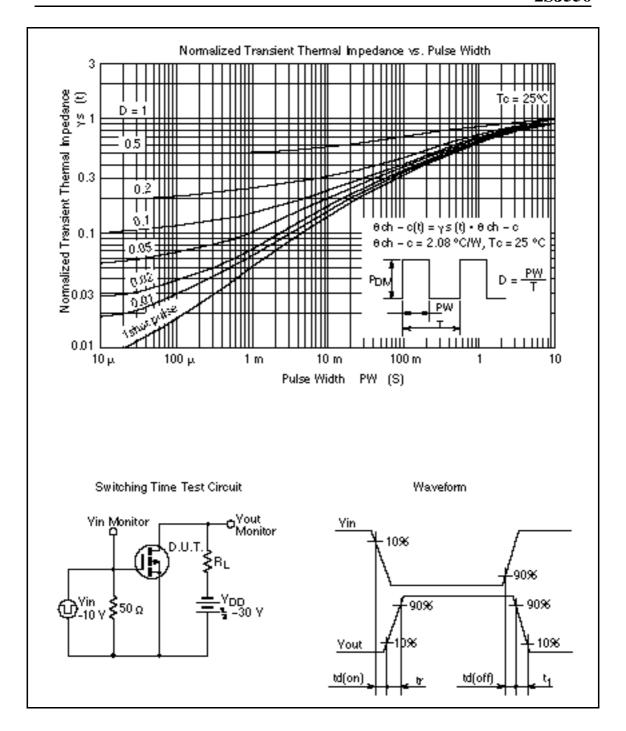
Main Characteristics





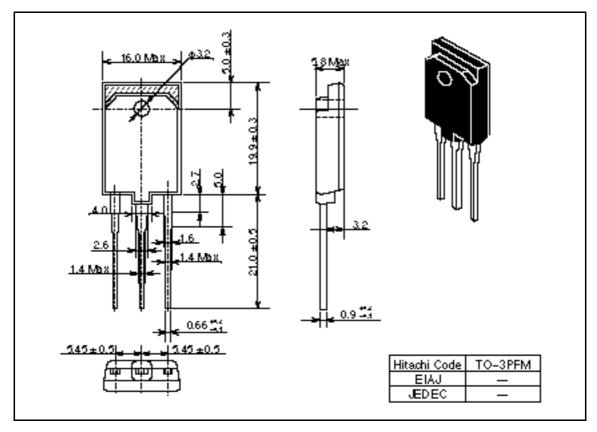






Package Dimensions

Unit: mm



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